



## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: IMAI, Genji

Group Art Unit: 1752

Serial No.: 09/976,279

Examiner: Yvette C. Thornton

Filed: **October 15, 2001** 

P.T.O. Confirmation No.: 1120

NEGATIVE PHOTOSENSITIVE RESIN COMPOSITION, NEGATIVE For. PHOTOSENSITIVE DRY FILM AND METHOD OF FORMING PATTERN

## **PETITION FOR EXTENSION OF TIME**

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

September 22, 2004

Sir:

Applicants petition the Commissioner for Patents to extend the time for response to the Office Action dated March 25, 2004 for three months, from June 25, 2004, to September 25, 2004.

Attached please find a check in the amount of \$950.00 to cover the cost of the extension for a large entity. In the event that any additional fees are due in connection with this paper, please charge our Deposit Account No. 01-2340.

Respectfully submitted,

09/23/2004 FMETEKI1 00000023 099/6279 ARMSTRONG, KRATZ, QUINTOS, HANSON & BROOKS, LLP

01 FC:1253

950.00 OP

Daniel A. Geselowitz, Ph.D.

Agent for Applicant Reg. No. 42,573

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PATENT TRADEMARK OFFICE